# Development of AC-LGAD detector with finer pitch electrodes for high energy physics experiments

Sayuka Kita<sup>1</sup>, Ikumi Goya<sup>1</sup>, Tomoka Imamura<sup>1</sup>, Koji Nakamura<sup>2</sup>, Kazuhiko Hara<sup>1</sup>

University of Tsukuba<sup>1</sup>, KEK<sup>2</sup>

University of Tsukuba

## Development of <u>AC-LGAD</u> detector with finer pitch electrodes for <u>high</u> energy physics experiments

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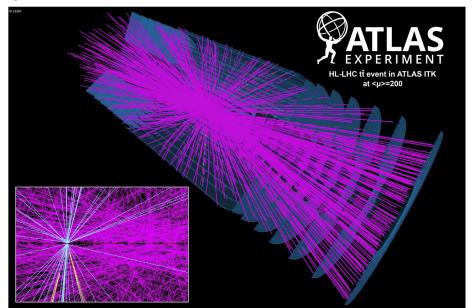
University of Tsukuba

### Detector for high energy physics experiments

High energy hadron collider

→ Higher particle density environment

e.g. expected pile up events for HL-LHC



Tracking becomes difficult due to pile up.

→ Timing information may help

Requirement for inner tracker in future hadron collider





One of strong candidates

#### LGAD sensor

It is difficult to get spatial resolution with standard LGAD design.

We are developing AC-LGAD to solve this problem

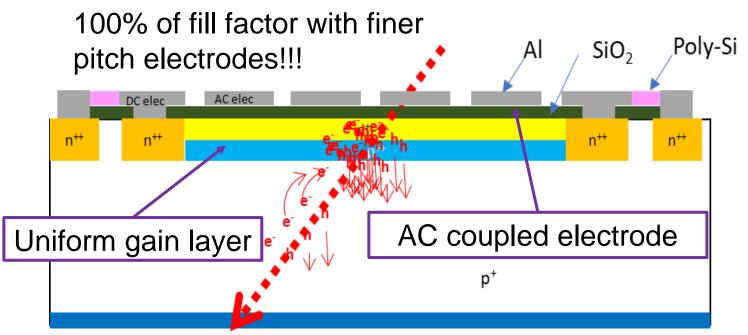
## AC-LGAD detector

#### **DC-LGAD** (standard LGAD)

Individual gain layer for each electrode

finer pitch: non-negligible inactive area exists

#### **AC-LGAD**



Potential issues of AC-LGAD

#### Crosstalk in n+ layer

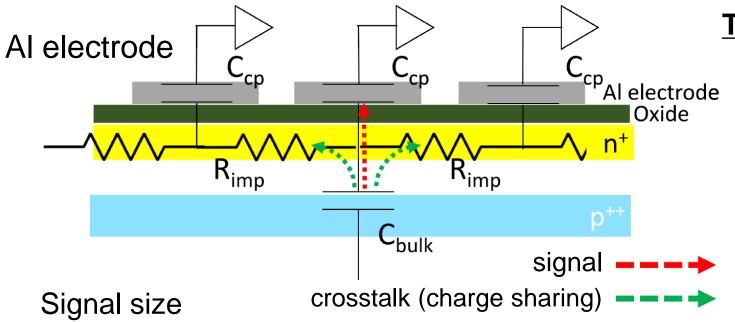
: critical in case of high occupancy environment

#### Smaller signal due to AC-coupling

: bad signal-to-noise ratio

## Signal readout model

What is the signal readout mechanism of AC-LGAD?



#### Two important parameters

R<sub>imp</sub> → larger is better : n+ doping concentration

**C**<sub>cp</sub> → larger is better

: Electrode size smaller electrode → smaller C<sub>cp</sub>

: Oxide thickness thinner oxide → larger C<sub>cp</sub>

: impedance ratio of  $R_{imp}$  and  $C_{cp}$ 

readout 
$$Q = \frac{Z_{R_{imp}}}{Z_{R_{imp}} + Z_{C_{cp}}} Q_0$$
 — generated charge

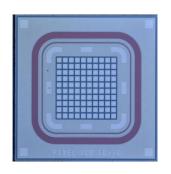
To keep larger signal and smaller crosstalk in finer pitch electrodes, larger n<sup>+</sup> resistivity and thinner oxide

## Prototype samples

To cover whole inner tracker with AC-LGAD sensors...

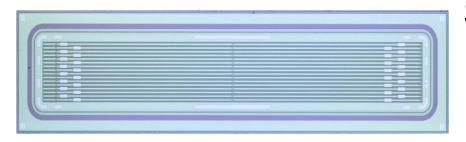
We prototyped following sensors in collaboration with HPK.

#### Electrode shape



#### **Pixel**

50, 100, 150, 200 um pitch (electrode size :40, 90, 140, 190um □)

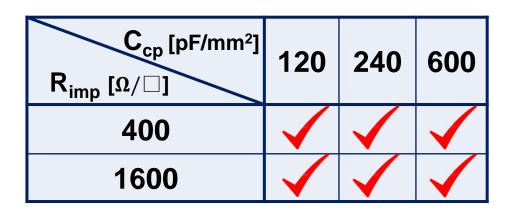


#### **Strip**

pitch: 80um length: ~1cm

width: 40, 45um

#### Parameter variation

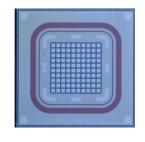


6types

## Pixel signal height (R<sub>imp</sub> and C<sub>cp</sub> dependence)

#### **Samples**

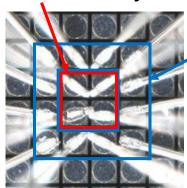
- 150um pitch pixel
- 6 parameter samples



- √ 2 types of R<sub>imp</sub> (n+ resistivity)
- ✓ 3 types of C<sub>cp</sub> (oxide thickness)

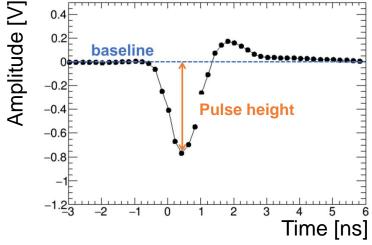
#### Readout channels

2x2 : analysis

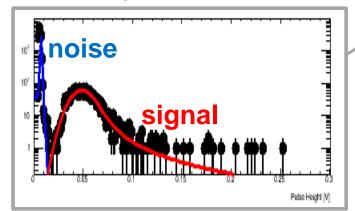


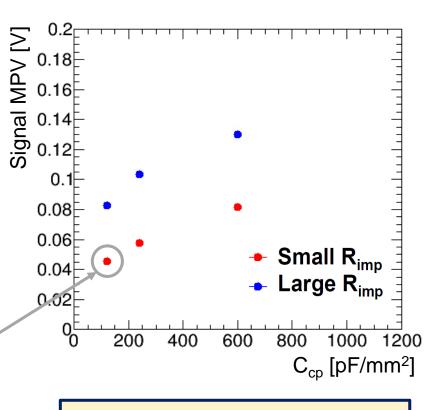
surrounded
12pixels
1
remove
crosstalk
effect

#### Pulse shape



Pulse height distribution



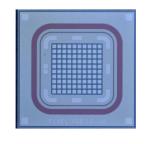


Larger R<sub>imp</sub> and C<sub>cp</sub> make signal larger

## Pixel signal height (R<sub>imp</sub> and C<sub>cp</sub> dependence)

#### **Samples**

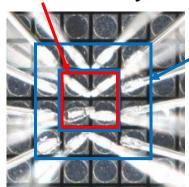
- 150um pitch pixel
- 6 parameter samples



- √ 2 types of R<sub>imp</sub> (n+ resistivity)
- ✓ 3 types of C<sub>cp</sub> (oxide thickness)

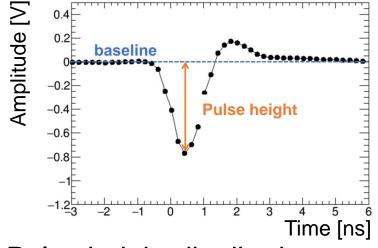
#### Readout channels

2x2 : analysis

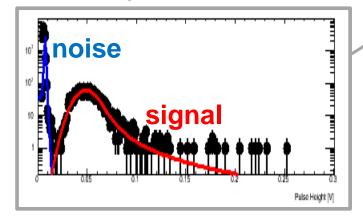


surrounded
12pixels
1
remove
crosstalk
effect

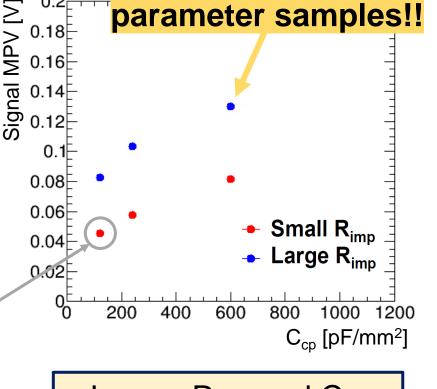




Pulse height distribution



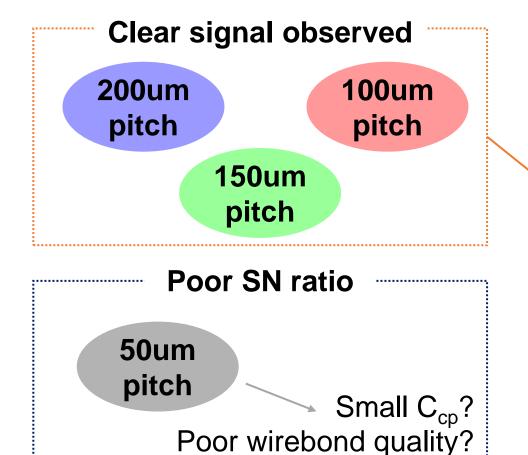
**Best optimized** 

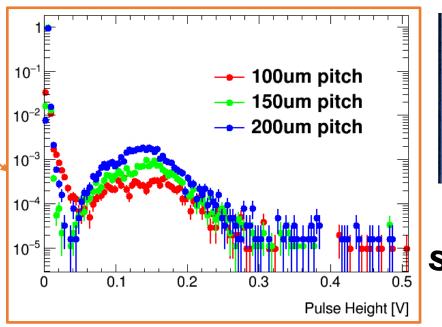


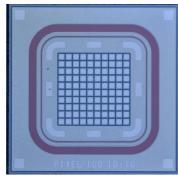
Larger R<sub>imp</sub> and C<sub>cp</sub> make signal larger

## Comparison of pixel pitches

Test samples with different pitches (max  $R_{imp}$  and max  $C_{cp}$ )



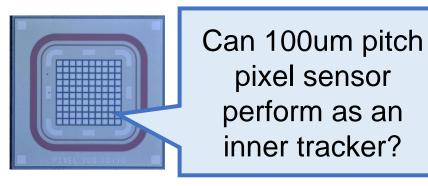




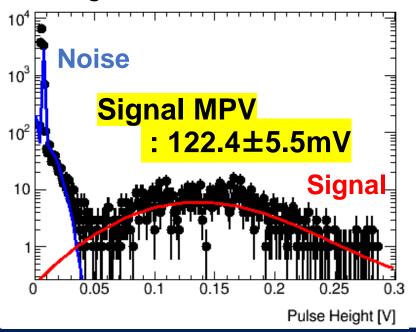
Good SN separation

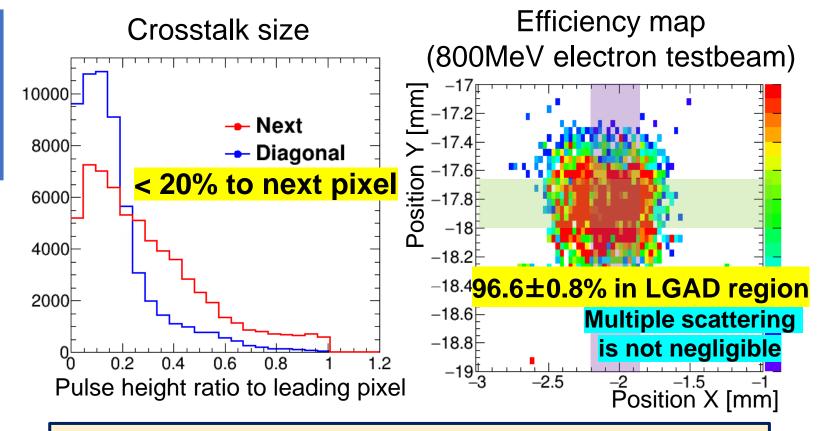
**100um pitch** pixel sensor is successfully working!

## Performance of 100um pitch Pixel sensor



#### Signal size distribution



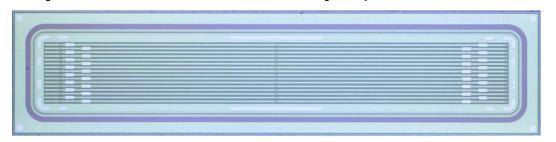


100um pitch pixel sensor has good performance

→ Next step: larger sensor (e.g. 2x2cm) with readout electronics (ASIC)

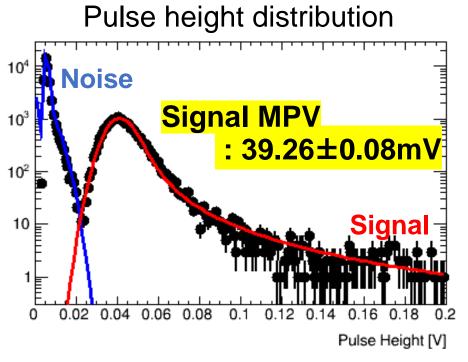
## Strip sensor performance

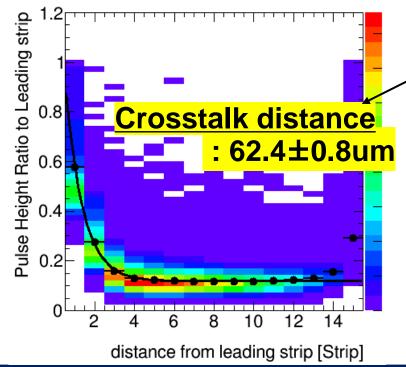
Strip sensor is necessary: pixel cannot cover full volume of inner tracker...



Max R<sub>imp</sub> and max C<sub>cp</sub> strip sample

- ✓ readout : 16strips
- ✓ electrode length x width : 9880 x 45um





distance constant of fitted exponential

80um pitch strip sensor has good performance

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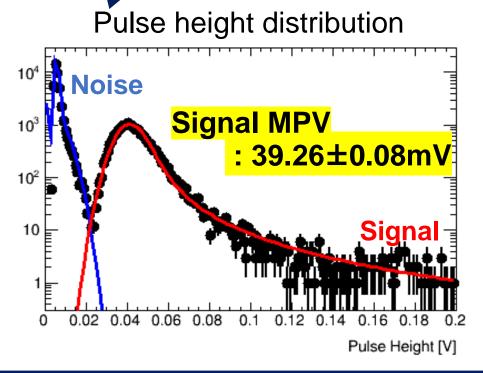
## Strip so performance

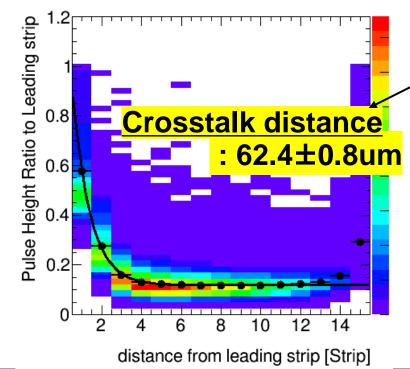
But rel cannot cov

vel cannot cover full volume of inner tracker...

Max R<sub>imp</sub> and max C<sub>cp</sub> strip sample

- ✓ readout : 16strips
- ✓ electrode length x width : 9880 x 45um





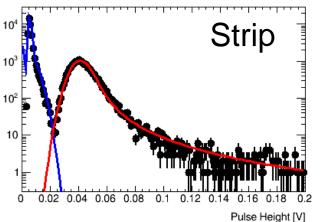
distance constant of fitted exponential

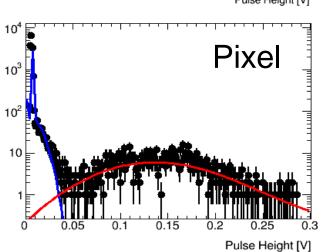
80um pitch strip sensor has good performance

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## Signal height of strip and pixel

Comparison of pulse height distribution between strip and pixel ...



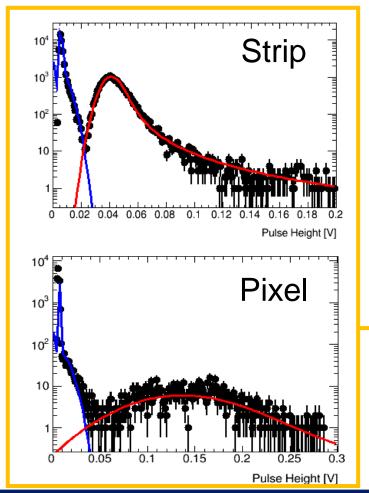


	Strip	Pixel
Area of electrode	9880x45 um <sup>2</sup>	100x100 um <sup>2</sup>
C <sub>cp</sub> size of electrode	large	small
Signal height (expected from C <sub>cp</sub> )	large	small
Signal height (actual result)	$39.26\pm0.08$ mV small	122.4 ± 5.5mV large

Why signal height is Strip < Pixel despite electrode area is Strip > Pixel?

## Signal height of strip and pixel

Comparison of pulse height distribution between strip and pixel ...

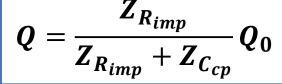


	Strip	Pixel
Area of electrode	9880x45 um <sup>2</sup>	100x100 um <sup>2</sup>
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## Signal height of strip and pixel

Comparison of pulse height distribution between strip and pixel



10 <sup>4</sup>	Strip
102	0.1 0.12 0.14 0.16 0.18 0.2
10 <sup>4</sup>	Pulse Height [V]
10 <sup>2</sup>	
0 0.05 0.1	0.15 0.2 0.25 0.3  Pulse Height [V]

	Strip	Pixel
Area of electrode	9880x45 um <sup>2</sup>	100x100 um <sup>2</sup>
C <sub>cp</sub> size of electrode	large	small
Signal height (expected from C <sub>cp</sub> )	large	small
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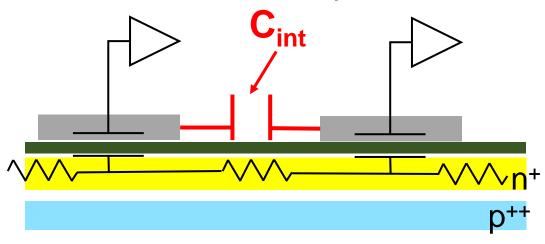
Why signal height is Strip < Pixel despite electrode area is Strip > Pixel?

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## Inter electrode capacitance

Result of small strip signal size comes from inter electrode capacitance effect

#### Inter electrode capacitance

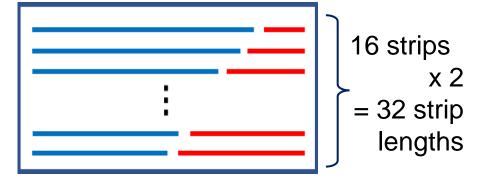


- ✓ equivalent circuit : capacitance between electrodes
- ✓ C<sub>int</sub> induces charge flow to next electrode
  - → Introduce additional crosstalk by this capacitance
- ✓ Strip sensor has larger C<sub>int</sub>

#### To check C<sub>int</sub> effect...

The sample has 32 variations of strip length by cutline

Pattern diagram



Compare signal from different lengths of strip

## Measurement of strips with cutline

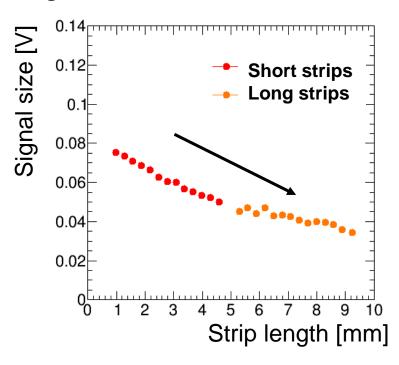
leading

channel

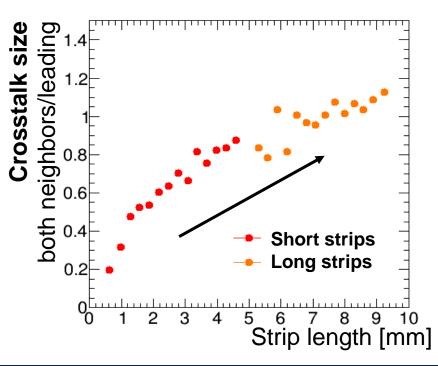
next of leading

channels

#### Signal size



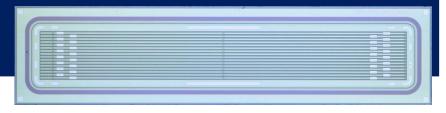
#### Crosstalk size



Strip sensor has large C<sub>int</sub>: Smaller signal and larger crosstalk

→ Sensors with longer strip length to cover large tracker area might be difficult... (e.g. 80um pitch and length much longer than 10mm isn't realistic in current design)

## Conclusion



For inner tracker in hadron collider,

finer pitch AC-LGAD sensors are prototyped with HPK.



Parameter optimization was performed.



successfully developed!!

Pixel (100um pitch)

→ larger area prototype with ASIC

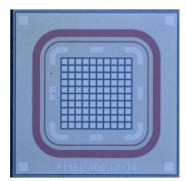
Strip (80um pitch)

C<sub>int</sub> makes strip signal smaller

→ Test longer strip sensor to check if the crosstalk effect is saturated

Todo

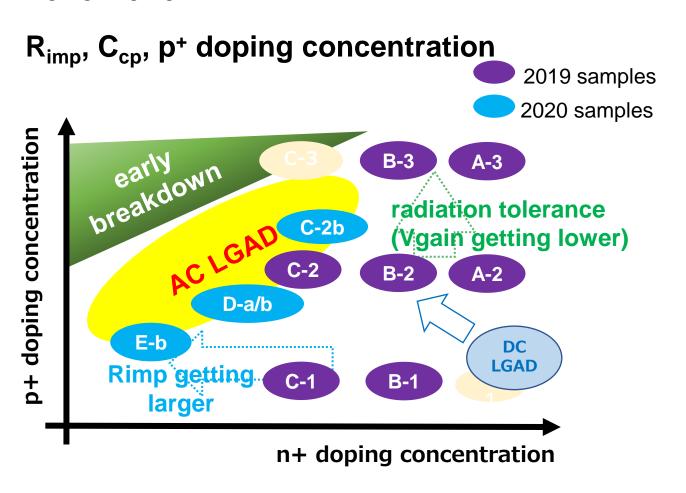
- Timing resolution
- radiation tolerance



## backup

## Samples

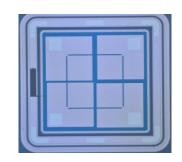
2019-2020



#### **Electrode shape**

Pad (4ch)

500um x 500um



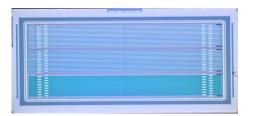
#### Strip (16chx3)

80um pitch 9880um

x 30, 35, 40, 45um

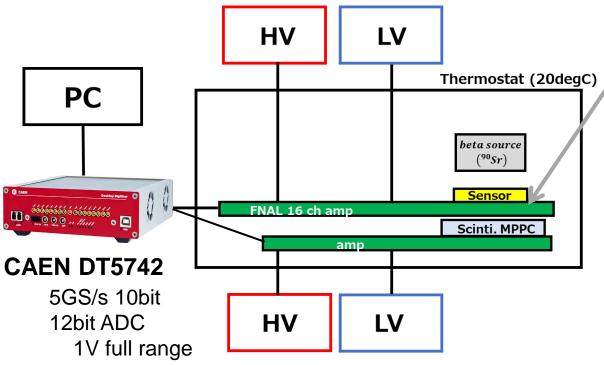
Pixel 50um pitch 42um x 42um





## Signal size measurement

Beta-ray measurement setup



KEKamp v7.3 No.2

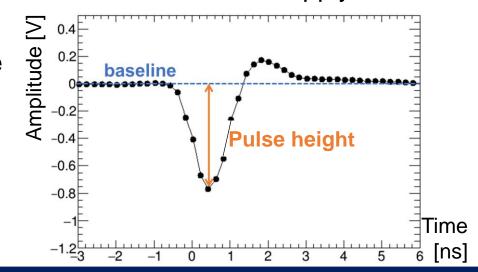
KEK16ch ampboard



Sensor is on conductive tape

→ supply HV behind

Pulse shape

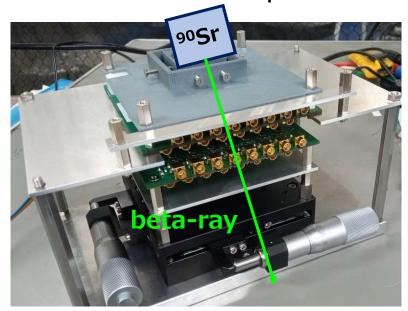


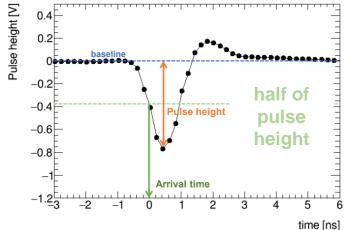
- ✓ Sensor is in thermostat keeping 20degC.
- ✓ Trigger is scinti. with MPPC

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## Timing resolution

1Pad sensor on ampboard stacked



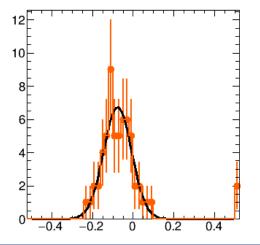


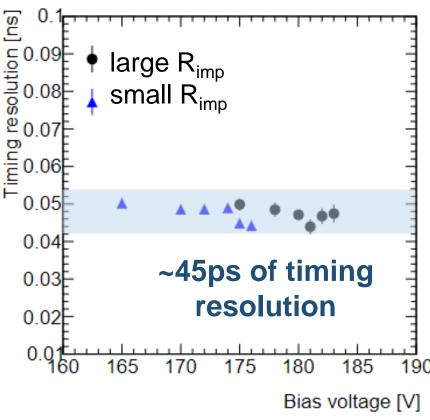
fitted arrival time difference by gaussian

→ calculated timing resolution



$$\sigma_t = \sigma(T_1 - T_2)/\sqrt{2}$$





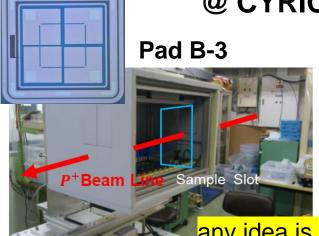
- ~45ps of timing resolution
- Why is not 30ps?
  - → need to investigate

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## Radiation tolerance

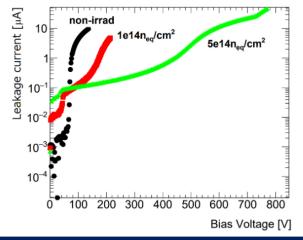
#### 70MeV Proton beam

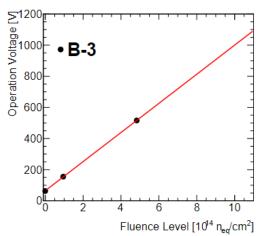
@ CYRIC (Tohoku University)



- V<sub>bd</sub> is getting larger with irradiated level
- > 700V cannot supply because of sensor design

any idea is needed for accepter removal





## 60Co gamma irradiation@ Takasaki gamma facility

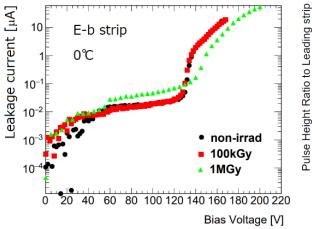


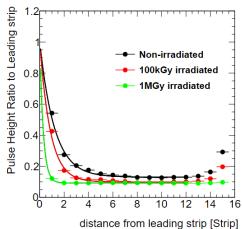


Strip E-b

- Vbd is not change large
- xtalk is supressed

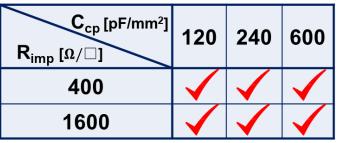
gamma makes sensor performance good





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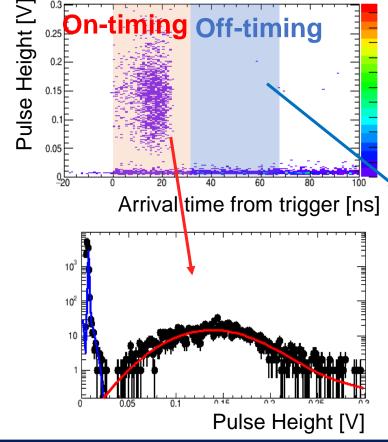
## Pulse height analysis

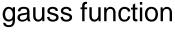


#### **Pulse height distribution**

fit off-timing by asymmetric gauss

→ fit on-timing by landau convoluted





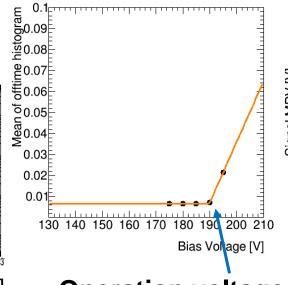
## 

#### **Operation voltage**

do voltage scan

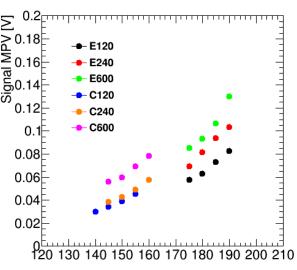
→ cross point which two fitted linear function in mean of off-time histogram is operation voltage

#### e.g. pixel 150um E240



#### **Operation voltage**

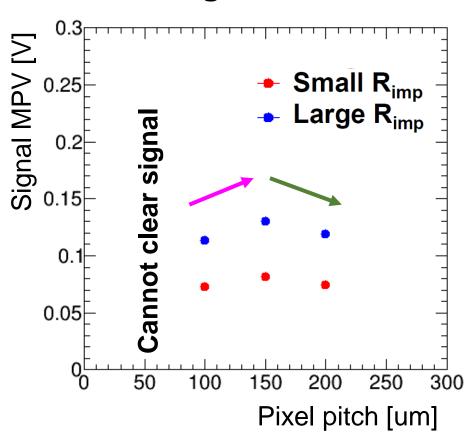




Bias Voltage [V]

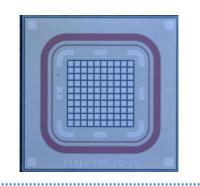
## Pixel signal size (pitch dependence)

#### Signal size



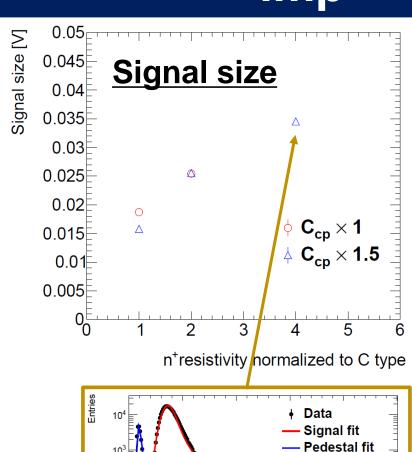
#### Measured samples

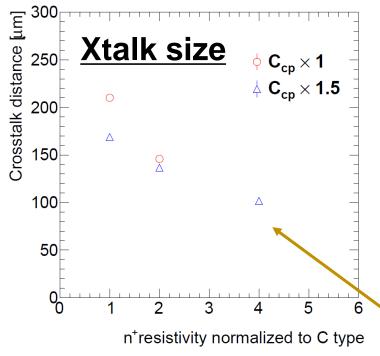
- C<sub>cp</sub>: 1type (largest one)
- R<sub>imp</sub>: 2type
- Electrode pitch
  - : 50, 100, 150, 200um pitch

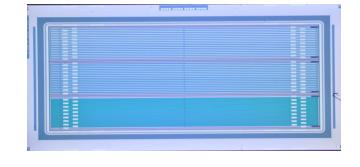


- ✓ Signal size is not changed significantly
- ➤ Signal increase area : 100~150um due to C<sub>cp</sub> by electrode size ?
- ➤ Signal decrease area: 150~200um due to inter pixel capacitance effect?

## Strip R<sub>imp</sub> and C<sub>cp</sub> dependence







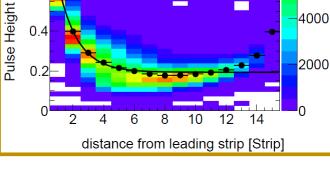
Crosstalk distance

: 100.0±0.2mV





strip

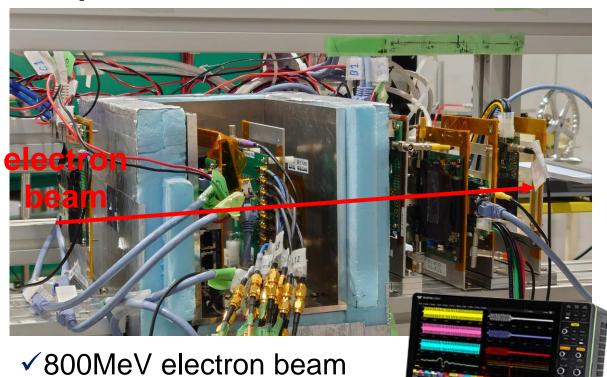


Signal MPV : 34.46±0.02mV

Pulse Height [V]

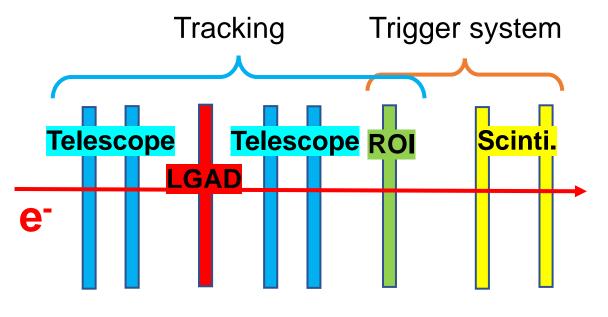
## Testbeam at ELPH (Tohoku University)

#### **Setup**



✓ beam rate : 200 ~ 400 Hz

✓ beam current: 14.38mA



non-negligible multiple scattering

WaveRunner 8208HD 2GHz, 8ch, 10GS/s, 12bit

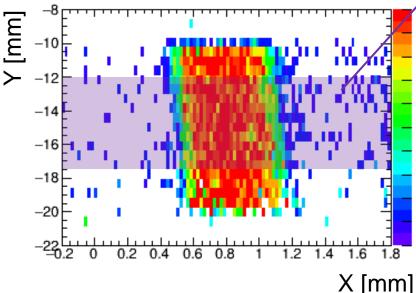
Pixel sensor (25x500um)

Pixel sensor (50x250um) Specify region

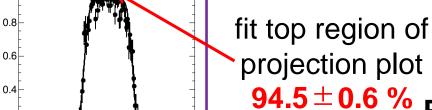
Strip efficiency (testbeam)

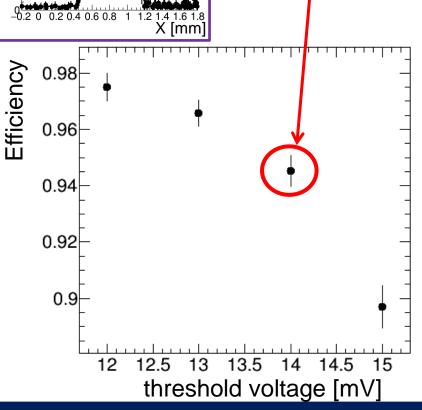
- ✓ Sensor : Strip E-b
- ✓ Bias voltage: 170V
- ✓ channel: 9~15ch

Efficiency map projection

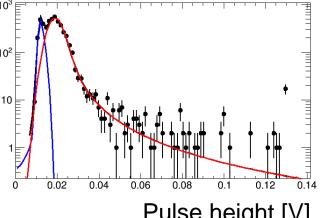


Efficiency of strip is >95%!!!





Pulse height distribution



Pulse height [V]

consistent to efficiency calculated from pulse height distribution

## Strip spatial resolution (testbeam)

✓ Sensor : Strip E-b

✓ Bias voltage: 170V

✓ channel: 10~14ch

✓ Number of events : ~600,000

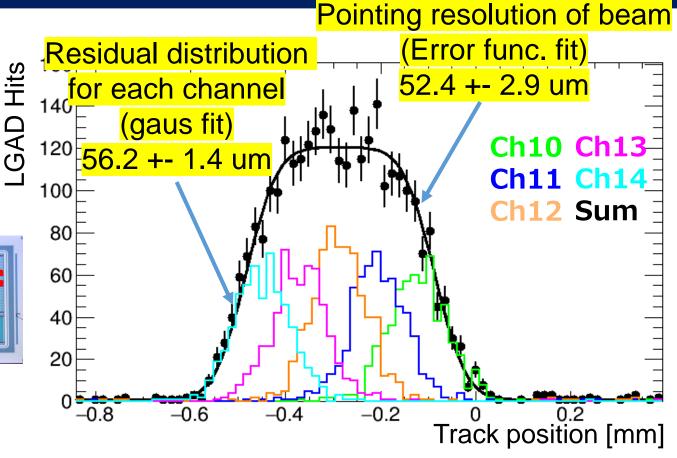
#### **Event selection**

✓ Good tracks

: have hits for all tel and ROI

 $: \chi^2/NDF : < 18 (x,y)$ 

✓ LGAD hit : > 14mV (95%efficiency)

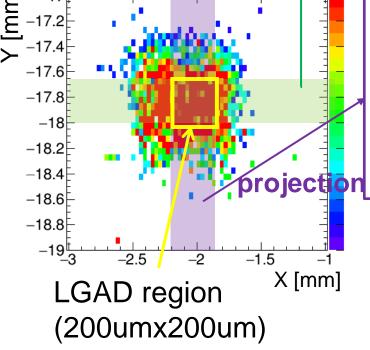


Spatial resolution of strip: 20.3±3.2um assuming spatial resolution of 80um pitch strip (binary readout): 80/sqrt(12) = 23um

## Pixel efficiency (testbeam)

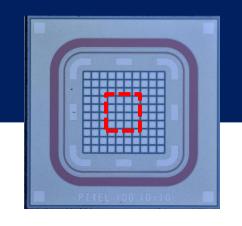
- ✓ PixelE600 (100um pitch)
- ✓ Bias voltage: 190V
- ✓ channel: 1~16ch

#### **Efficiency map**



#### **Event selection**

- ✓ Good tracks
  - : have hits for all tel and ROI
  - $: \chi^2/NDF : < 20 (x,y)$
- ✓ LGAD hit: Threshold at noise rate 10<sup>-4</sup>



#### Pointing resolution of beam

 $X:62.3\pm17.4um$ 

Y: 136.8±20.8um

multiple scattering..

Y pointing resolution of beam is worse than X
→ Efficiency X is poor

